

## Main Unit Spec

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Model Type	i-Line (365 nm) Stepper
Wafer Size	Optional Substrate Size: 50 mm, 75 mm, 100 mm, 150 mm, 200 mm
Resolution	$\leq 0.8 \mu\text{m}$
Numerical Aperture (NA)	0.16 - 0.24
Reticle Size	6 in. (0.25 in. thick); 5 in.*
Reduction Ratio	2:1
Field Size	52 mm x 52 mm
Overlay Accuracy	$\leq 100 \text{ nm } ( m  + 3\sigma)$